

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	(titanium Ti) near20 (LPCVD (low pressure near3 pressure near3 (CVD (chemical vapor near3 vapor near3 deposit\$3)))) near20 ((titanium near3 chloride) TCI4 ("Ti" adj2 "Cl.sub.4")))	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:20
L2	1089402	insulat\$3 dielectric	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/08 12:21
L3	349616	L2 and (via contact hole open\$3)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/08 12:21
L4	17565	L3 and (source and drain)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/08 12:21
L5	0	L4 and (titanium (titanium near3 nitride) Ti TiN)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:21
L6	86	(protection getter gettering sacrificial) near15 (source drain) near15 (titanium Ti)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:22
L7	337	(protection getter gettering sacrificial silicon polysilicon (poly near3 crystalline near3 silicon)) near15 (source drain) near15 (titanium Ti)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/08 12:22
L8	0	L7 and (silicide salicide)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:22
L9	41085	silicide salicide	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23
L10	23483	L9 and (silicon near3 substrate)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23
L11	22033	L10 and (via open\$3 contact hole)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23
L12	14019	L11 and (titanium Ti)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23
L13	8239	L12 and ((titanium near3 nitride) TiN)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23
L14	6899	L13 and (source drain)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23

L15	5917	L14 and gate	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23
L16	4520	L15 and (polysilicon (poly near3 crystalline near3 silicon))	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23
L17	229	L16 and ((raised elevated) near5 (source drain))	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:23
L18	4	(LPCVD (low near3 pressure near3 cvd)) with (titanium Ti) with ((titanium near5 chloride) TiCl4)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:28
L19	13	(LPCVD (low near3 pressure near3 cvd)) same (titanium Ti) same ((titanium near5 chloride) TiCl4)	US-PGPUB; USPAT; USOCR	OR	ON	2005/02/08 12:31
L20	4	(LPCVD (low near3 pressure near3 cvd)) same (titanium Ti) same ((titanium near5 chloride) TiCl4)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/08 13:28